



High Efficiency Thermal Management

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Thermal Issues in HiFIVE

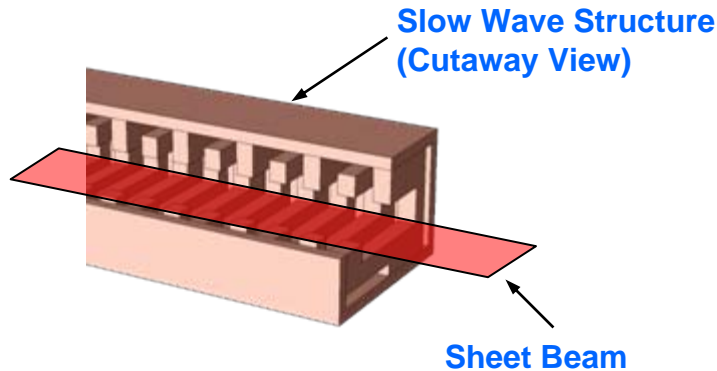


- Combined high power and high frequency lead to high power density in the interaction structure
 - Beam interception, RF losses
- Need to control interaction structure temperatures
 - Thermal expansion (dimensional changes)
 - Thermal cycling (reliability)
 - Outgassing
- Additional thermal constraints (or advantages!) on microfabricated structures & materials suitable for microfabrication vs. standard vacuum electronics
- Beam collector also presents thermal issues
- Attention to high efficiency (compact) thermal management is required

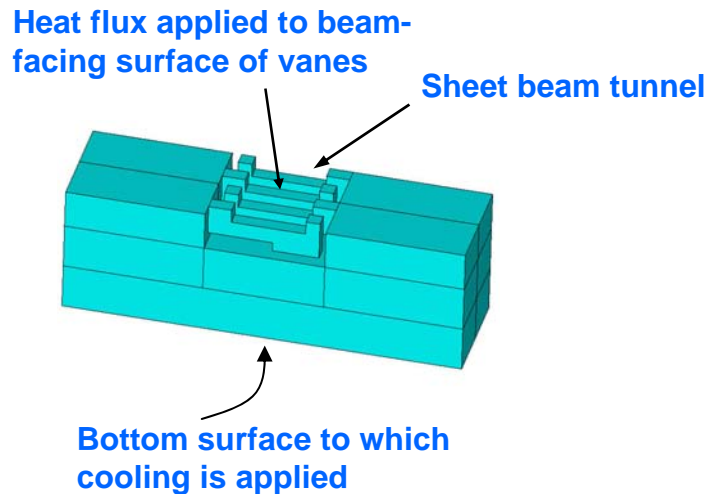
A seedling study on thermal issues was performed at NRL under DARPA/MTO sponsorship



Assumptions for the Seedling Thermal Study



Example Geometry for Thermal Study



View of $\frac{1}{2}$ of the Structure for Thermal Modeling

- Sheet beam with 5:1 aspect ratio*
- Broadband coupled cavity traveling wave structure
- Beam scraping and RF losses contribute to waste heat in general
 - Beam scraping was assumed to be the dominant source of waste heat for the analysis
- 10% beam scraping* total was assumed to occur over the final portion of a typical interaction structure
 - About 1.45 cm length at 220 GHz (based on scaling from W-band devices)

** Note that parameters for this seedling study were for initial estimation purposes only, and that in actual designs the Go/No-Go metrics in the BAA must be used, plus details of the actual combined beam interception and RF losses in performer structures*



220 GHz CW Heat Flux Levels



50 W CW Output Power at 2.5% efficiency or

100 W CW Output Power at 5% efficiency

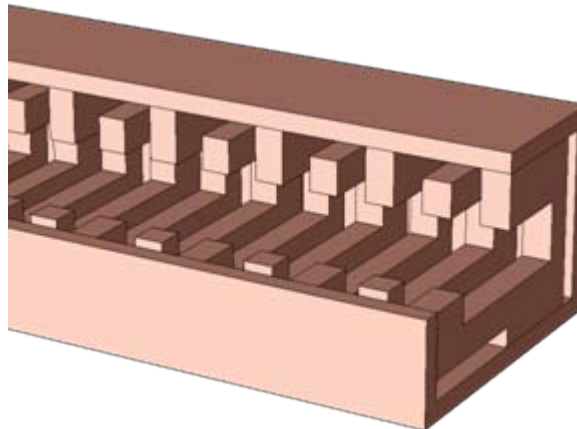
→ 2000 W of beam power

× 10% beam scraping

→ 200 W dissipated power in structure

Area = 1.45 cm long x 0.16 cm wide (for 5:1) x 2 (top & bottom) x 0.5 (50% vane coverage)
= 0.10 cm²

→ 2000 W/cm² on vane surfaces

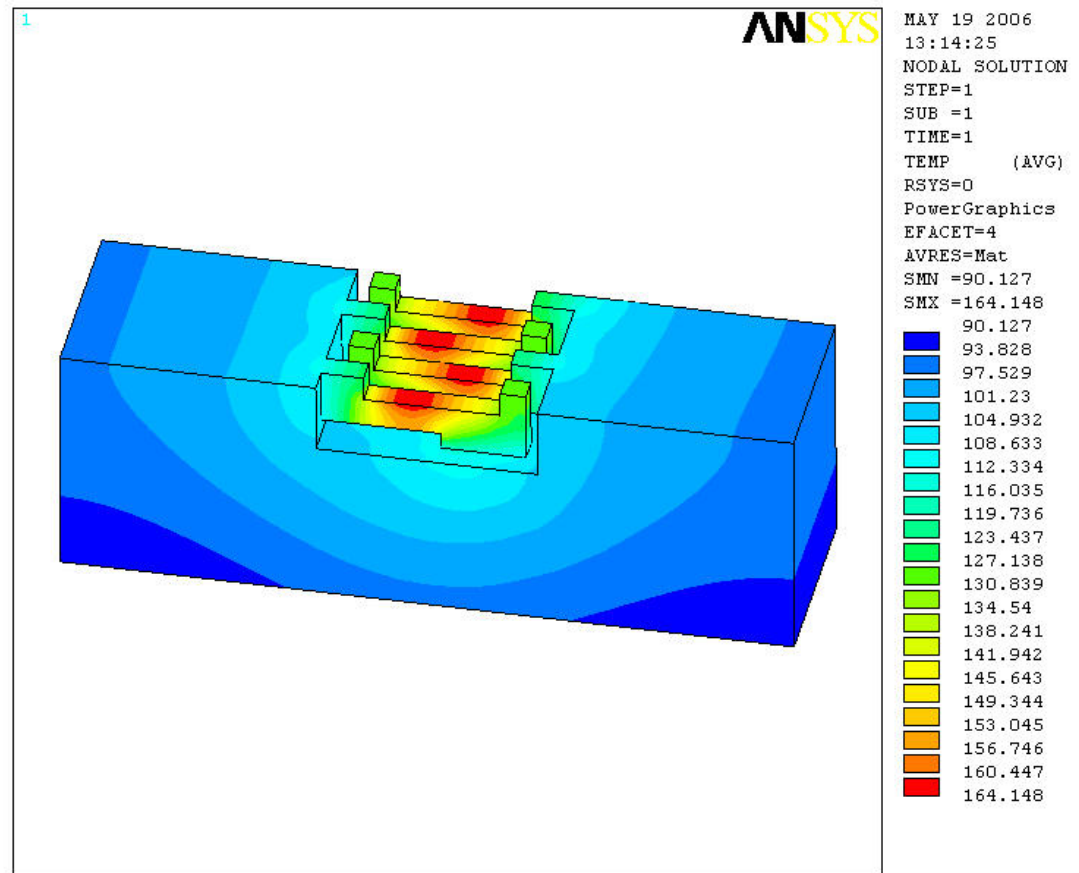




Typical Analysis Results



- Material is copper ($\kappa = 3.85 \text{ Wcm}^{-1}\text{K}^{-1}$)
- Rear heat transfer coefficient
 - $2.5 \text{ Wcm}^{-2}\text{K}^{-1}$ @ 20°C bulk
 - Consistent with several types of moderately aggressive cooling approaches
- Peak structure temperature 164°C
- Rear temperature $\sim 97^\circ\text{C}$



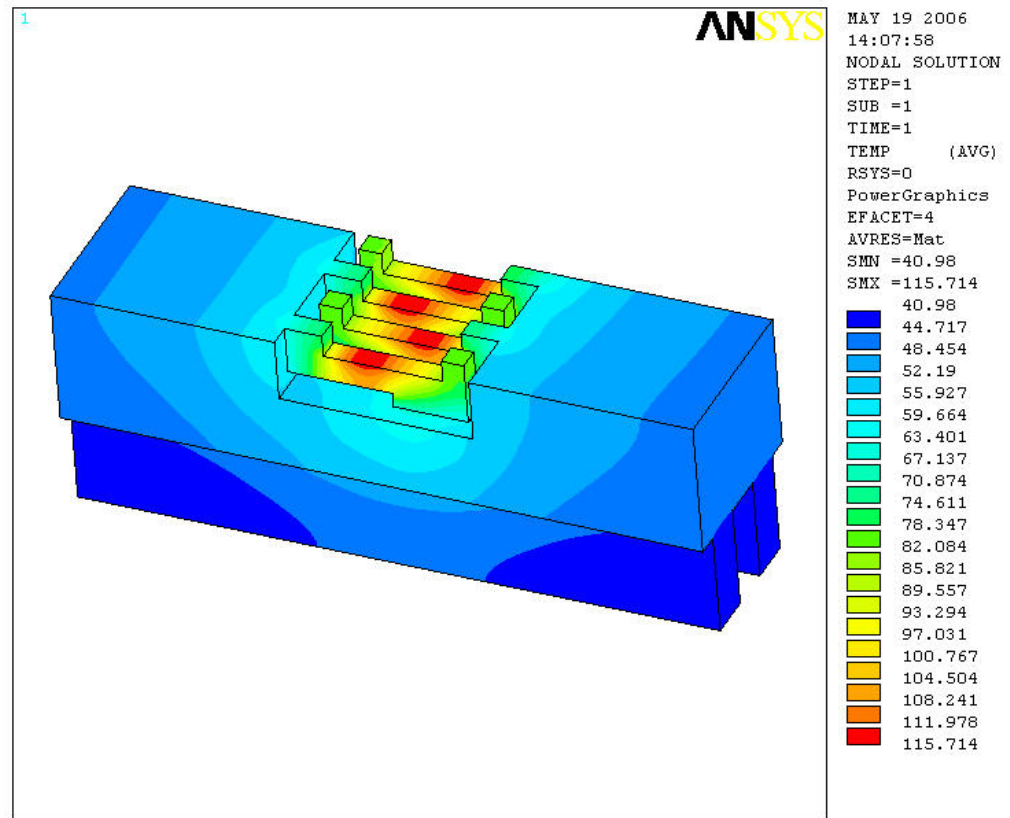
Temperatures ($^\circ\text{C}$) in a 220 GHz copper sheet beam TWT structure, with a CW power density of 2 kW/cm^2 on the vanes (corresponds to 50 W output power if efficiency = 2.5%)



Example with Microchannel-Based Liquid Cooling



- Material is copper ($\kappa = 3.85 \text{ Wcm}^{-1}\text{K}^{-1}$)
- Microchannel cooling on rear
 - $250 \mu\text{m}$ wide by $600 \mu\text{m}$ tall channels
 - 5 m/s water flow velocity
 - 20°C bulk water temperature
- Peak structure temperature 116°C
- Peak coolant channel temperature $\sim 55^\circ\text{C}$



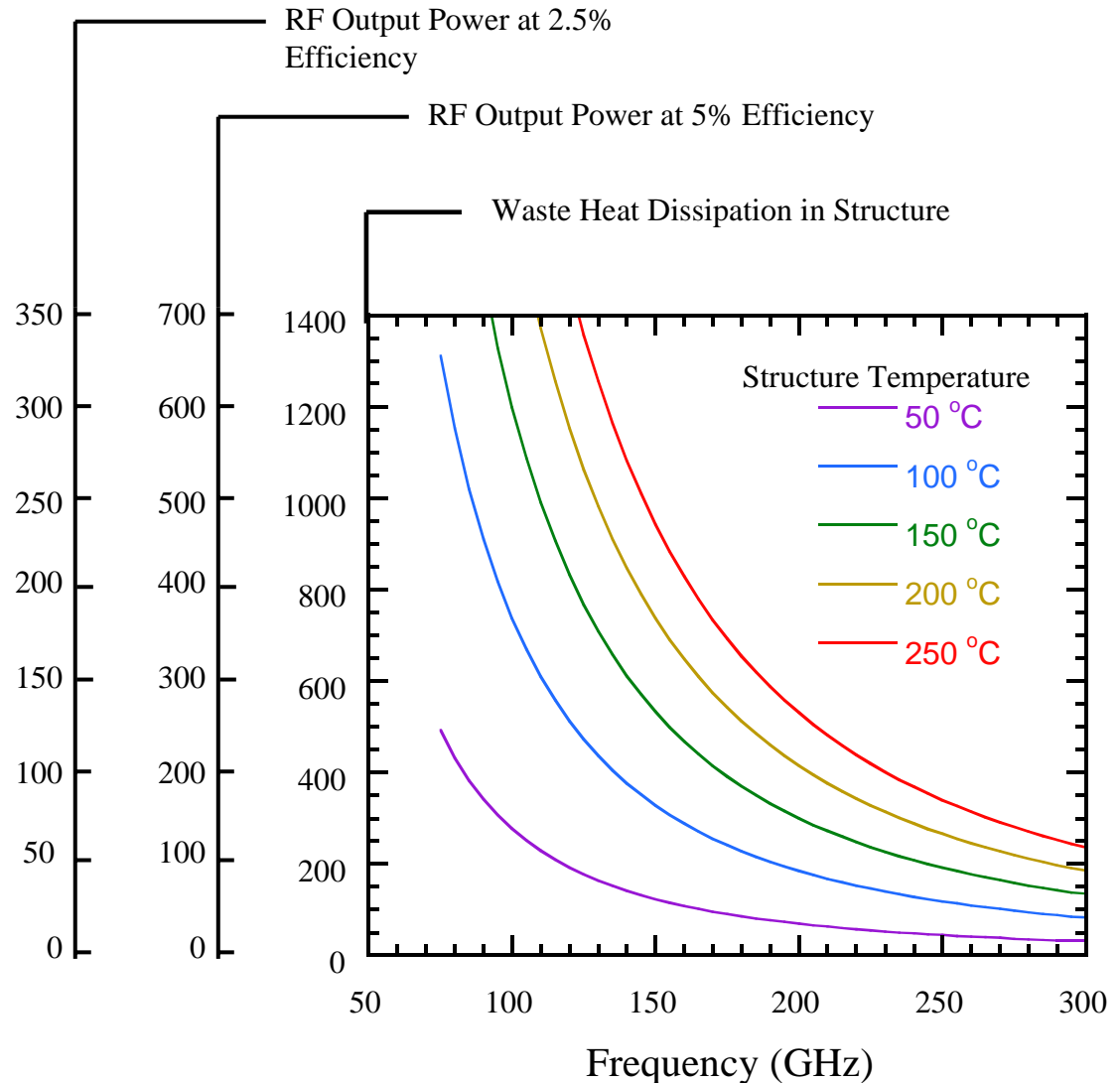
Temperatures ($^\circ\text{C}$) in a 220 GHz copper sheet beam TWT structure using a microchannel cooler, with a CW power density of 2 kW/cm^2 on the fingers (corresponds to 50 W output power if efficiency = 2.5%)



Scaling of Power Levels with Frequency and Allowable Structure Temperature



- All dimensions assumed to be scaled as $1/f$, where f is the frequency
- Material is copper
($\kappa = 3.85 \text{ Wcm}^{-1}\text{K}^{-1}$)
- Microchannel cooling on rear
- Microchannel dimensions also scaling as $1/f$
- 10% beam interception assumed
- Curves for various peak structure temperatures are shown

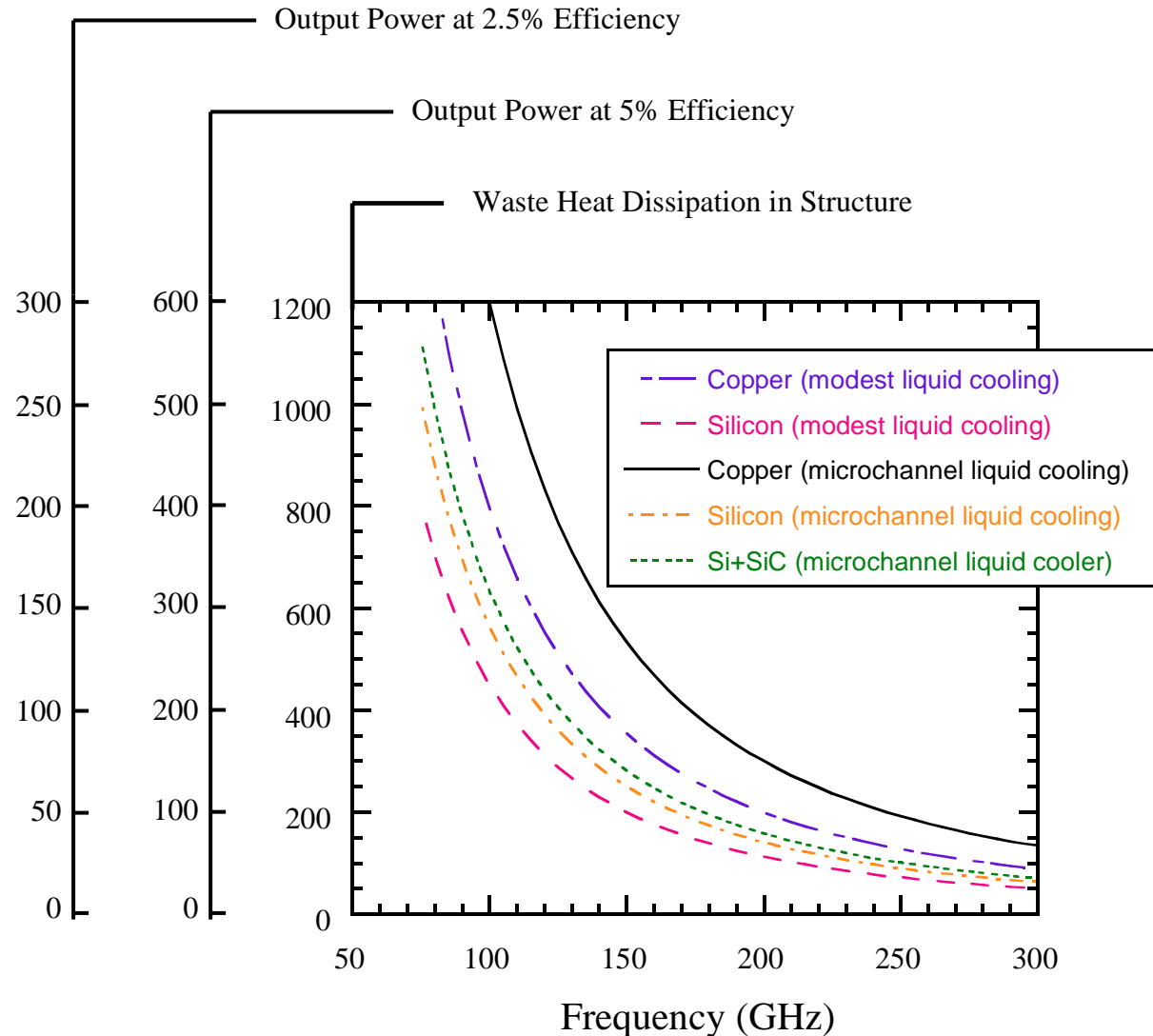




Scaling Curves for Different Structure Materials and Cooling Technologies

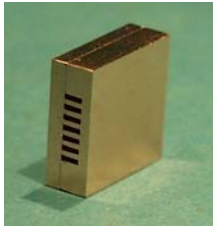


- Copper ($\kappa = 3.85 \text{ Wcm}^{-1}\text{K}^{-1}$)
- Silicon ($\kappa = 1.50 \text{ Wcm}^{-1}\text{K}^{-1}$)
(has thin metal coating for RF)
- Modest liquid cooling and microchannel cooling both examined
- Silicon on polycrystalline CVD SiC microchannel cooler also examined

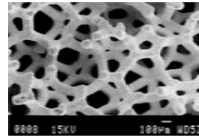
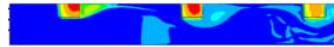




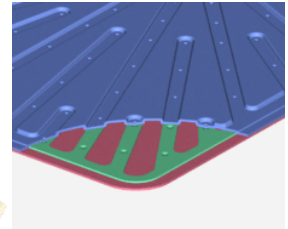
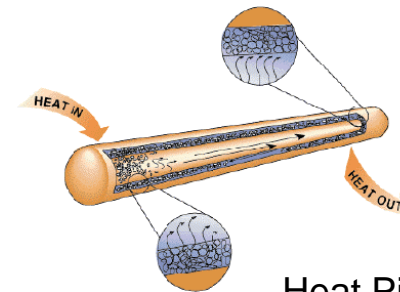
A Potpourri of Possible Thermal Management Techniques



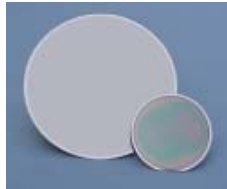
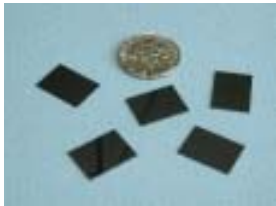
Microchannel Coolers



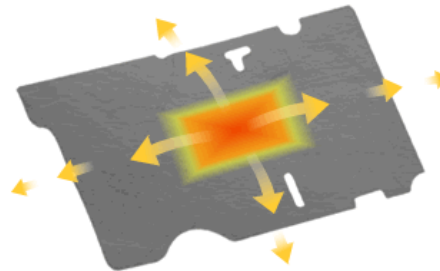
Pin-Fin and Foam-Based Cold Plates



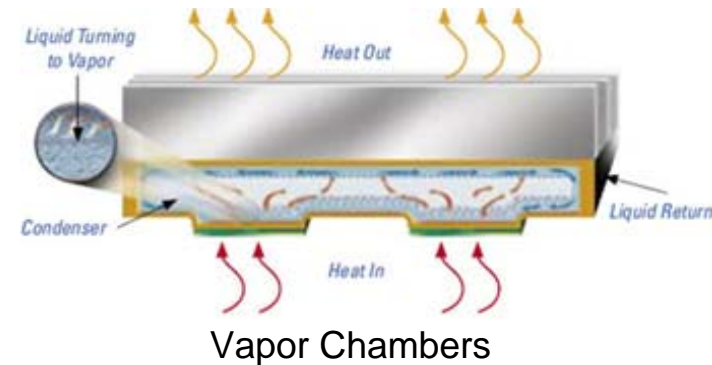
Heat Pipes



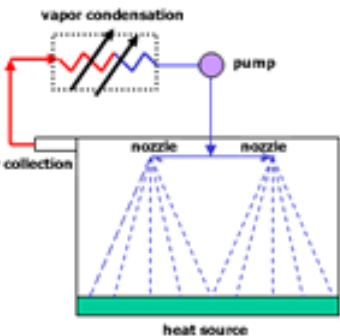
CVD Diamond Structures, Layers, & Composites



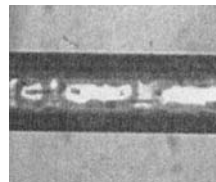
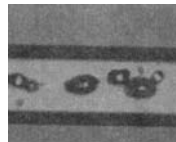
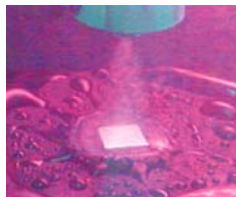
Graphite Layers



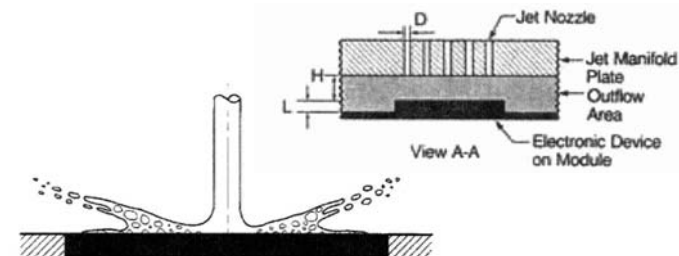
Vapor Chambers



Spray Cooling



Forced 2-Phase Cooling



Liquid Jet Cooling



Summary



- Dissipated power densities can be above 1 kW/cm² in the interaction structure
- Beam collector is also a region of concern
- Continuous-wave, reliable device operation is required
- High efficiency thermal management is needed to handle the high heat fluxes in a compact manner
- Example analysis shows that thermal management needs are consistent with several approaches / materials systems
- A wide variety of emerging thermal management techniques could be appropriate